

Amendments to the Specification:

Please amend the specification as follows:

Immediately after paragraph [0044], please add the following new paragraph:

Fig. 24 is a flowchart showing a process used in fabricating a liquid crystal display in accordance with an embodiment of the present invention.

Immediately after paragraph [0069], please add the following new paragraph:

In Fig. 24 there is flowchart that illustrates a process used in fabricating a liquid crystal display in accordance with an embodiment of the present invention with the steps of: preparing a substrate having a major surface (S1); patterning a first conductive material layer into plural gate layers and plural storage electrode layers on the major surface (S2); covering the plural gate layers and the plural storage electrode layers with a gate insulating layer (S3); patterning an amorphous silicon layer into plural amorphous silicon layers on the gate insulating layer (S4); selectively etching the gate insulating layer together with pieces of residual amorphous silicon to form plural bent contact slits in the gate insulating layer (S5); patterning a second conductive material layer into plural drain layers and plural source layers (S6); patterning a transparent material layer into pixel electrodes respectively held in contact with the plural source layers (S7); and depositing dielectric material over the surface of the resultant structure (S8). The process ends in (S9).